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10540056 - GAU: 1795

PTO/SB/08 Equivalent

	Application No.	10/540,056
INFORMATION DISCLOSURE	Filing Date	June 22, 2005
STATEMENT BY APPLICANT	First Named Inventor	Sato et al.
STATEIVILINI DI AFFLICANI	Art Unit	1795
(Multiple sheets used when necessary)	Examiner	John S Y Chu
SHEET 1 OF 2	Attorney Docket No.	SHIGA7.021APC

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Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	
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	8	JP 2003-107707	04-09-2003	Clariant (Japan) KK		√ abstract
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Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>	
	21	Office Action Issued on July 1, 2008, on the Japanese Patent Application No. 2004-142581.		

Examiner Signature	/John Chu/	Date Considered	10/02/2009

<sup>\*</sup>Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Receipt date: 10/06/2008

INFORMATION DISCLOSURE

STATEMENT BY APPLICANT

(Multiple sheets used when necessary)

SHEET 2 OF 2

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SHIGA7.021APC

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## ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /JSC/

Examiner Signature	/John Chu/	Date Considered	10/02/2009
	erence considered, whether or not	citation is in conformance with MPEP 60	

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.